Supporting Information

The Role of Surface Chemistry of Ceria Surfaces on the Silicate Adsorption

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Figure S1. TEM images of (a) calcined ceria and (b) solution-grown ceria.



Figure S2. The FT-IR spectra of calcined ceria.



Figure S3. Electrokinetic behaviors of calcined ceria as a function of pH.



Figure S4. The XPS spectra of Ce 3d of ceria.



Figure S5. Langmuir plots for adsorption isotherm of PAA on ceria.



Figure S6. Freundlich plots for adsorption isotherm of PAA on ceria.

Experimental conditions			
Slurry	Ceria slurry		
Solid concentration of slurry	1.0wt%		
Pad	IC 1000/ Suba IV		
Table speed	70rpm		
Down force	4 psi		
Polishing Time	60s		
Flow rate	100 mL/min		

Table S1. CMP conditions.

	CeO ₂ (wt%)	С	Н	Ν	S
NO ₃ -Ceria	99.41	0.27	0.22	0.10	N/A
OH-Ceria	98.92	0.72	0.35	N/A	N/A

 Table S2. Elemental composition of ceria

	NO ₃ -Ceria	OH-Ceria
Ce ³⁺ percent (%)	7.8 %	10.7 %
Ce ⁴⁺ percent (%)	92.2 %	89.3 %
Ce(III)/Ce(IV) ratios	0.085	0.119

 Table S3. The Ce(III)/Ce(IV) ratios of ceria.

	Langmuir constant		Freundlich constant			
	$Q_m (mg/m^2)$	K_L (L/mg)	\mathbb{R}^2	$K_{\rm F}$	n	\mathbb{R}^2
NO ₃ -Ceria	0.2247	0.0123	0.9930	0.0449	4.3365	0.7838
OH-Ceria	0.2041	0.0078	0.9905	0.0258	3.4387	0.8666

Table S4. Langmuir and Freundlich constants of PAA adsorption on ceria.